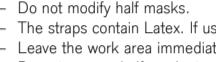


Zekler 1300 Series

EN	Particulate filtering half mask
SV	Partikelfilterande hälvmask
DA	Partikelfiltrerende hælvmask
NO	Partikelfiltrerende halmask
FI	Hukkassudottava puolinamari
FR	Demi-masque filtrant contre les particules
DE	Partikelfiltrierende Halbmaske
ES	Mascarilla autofiltrante para partículas
EL	Μάσκα ουρηνόβιων πυρού προστασίας
IT	Semifaciale filtro per polveri
PT	Semi-máscara filtrante de partículas
IS	Agríðslufárhús
NL	Deelhalsfilterende halfmasker
PL	Półmaska z filtrem cząstek stałych



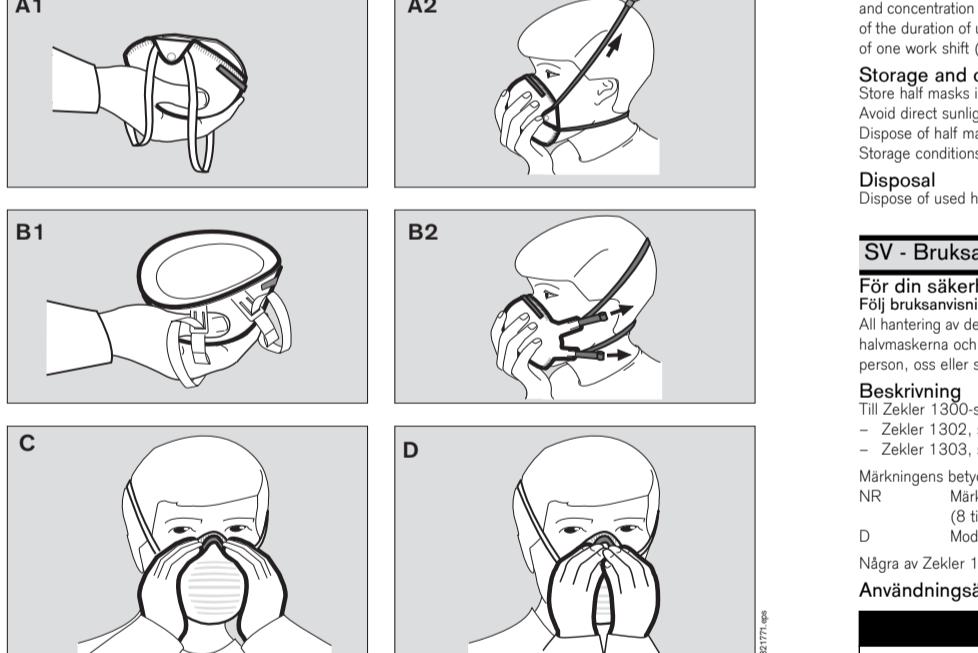
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39 50 516 - © Zekler-Safety
Edition 02 - August 2018 - Subject to alteration



EN - Instructions for Use

For your safety

Strictly follow the instructions for use. Any use of the particle filtering half masks requires full understanding and strict observation of these instructions for use. The particle filtering half masks are only to be used for the purpose specified here. In case of queries please contact your safety officer, us or see EN 529-2005.

Description The Zekler 1300 series includes the following particle filtering half masks (hereafter also called "half-masks"):

- Zekler 1302, protection class FFP2
- Zekler 1303, protection class FFP3

Meaning of the markings: "NR" means that the particle filtering half mask may only be used for a maximum of one work shift (8 hours).

D Variant having passed the Dolomite clogging test against clogging.

Some Zekler 1300 have an evaluation value ("V"), making exhalation easier.

Intended use

The particle filtering half masks are only to be used for the purpose specified here. Misuse can cause illness or death!

Declaration of conformity: see www.zekler.com/Declaration-of-conformity

The half masks have been tested and approved in accordance with (EU) 2016/425 and EN 149:2001+A1:2009.

The half masks are only to be used for protection against gasses, vapours or chemical, biological, radioactive and nuclear warfare agents.

The oxygen content of the ambient air must not be below the following limit values:

- 19 vol.-% in the Netherlands, Belgium, UK, Australia, New Zealand.

For other countries, observe the national regulations.

- Never enter unventilated areas, pits, canals, etc. while wearing half-masks.

- These half masks do not include complete warning notices or recommendations of use for personnel in the health sector or other areas where contact with infectious germs or biologically harmful substances is possible. Information on this topic is available from the hygiene officer or Zekler Safety.

- The half masks are not intended for use as surgical masks.

- The ambient conditions (especially the type and concentration of pollutants) must be known. The maximum permitted concentration of the pollutants in the ambient air must not be exceeded.

Observe the limit values and limitations of use for the various half masks:

The half masks are only to be used for protection against solid and liquid non-volatile particles.

Observe the particle filtering half masks (specify type and concentration of specific dangerous substances).

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